### Progress Report on Chamber Clearing Code Development Effort

A. R. Raffray, F. Najmabadi, Z. Dragojlovic, J. Pulsifer, M. Zaghloul University of California, San Diego

> A. Hassanein Argonne National Laboratory

P. Sharpe, B. Merrill, D. Petti Idaho National Engineering and Environmental Laboratory

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### Strategy Include Careful Planning and Analysis Effort for Most Efficient Code Development

- Form team (UCSD, INEEL, ANL) and clearly define responsibilities 4
- Identify major processes, evolve model and determine key variables 4
- Perform scoping calculations to assess relative importance of competing 4 parameters and help prioritize inclusion of different processes in computer code
- Planning of code development includes:
  - Evolving overall code architecture
  - Identifying numerical solver package (already coded)
  - Identifying and assessing existing codes for calibration purposes of controlled cases, e.g.
    - CFDRC
    - HEIGHTS
    - RECON
- Code implementation and integration of packages



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# Team Assembled to Focus on Different Modules of the Chamber Physics and Clearing Code





### Major Processes Have Been Identified and Modeled e.g. Surface Vaporization

Physics	Kinetic model based on surface temperature, activation energies and su rface conditions.				
Model	• Velocity of receding surface from surface vaporization, V(T), is a highly nonlinear function of surface temperature (T) and is given by: $V(T) = 5.8 \times 10^{-2} \frac{\alpha \sqrt{AP_V(T)}}{\rho(T)\sqrt{T}} \left[ 0.8 + 0.2e^{-t/10\tau} C \right] \text{ cm/s}$ where $\alpha = \text{sticking probability or accommodation coefficient ($\approx 1$)}$ $A = \text{atomic mass number of target material}$ $P_V = \text{vapor pressure of target material (torr)}$ $\tau = \text{vapor collision frequency (s^{-1})}$ $\rho = \text{density of wall material}$				
Key Parameters	Surface temperature and accommodation coefficient.				
Key Uncertainties	Comparison of simple equilibrium- basis equation with dynamic case; might require correction terms.				
<b>Relative Importance</b>	One of major mechanism for chamber wall erosion.				
Time-Scale	Comparable to energy-deposition time-scale				
Spatial Location	Wall surface.				
Inter-relation with Other Processes	All processes affecting surface temperature evolution (i.e. energy deposition; thermal diffusion, condensation)				
Inclusion in Model	Above model is included from the start.				



# **Scoping Calculations Performed to Assess Importance of Different Effects and Conditions**

- Chamber Gas
  - At high temperature (> ~ 1 ev), radiation from ionized gas can be effective
  - In the lower temperature range (~ 5000K back to preshot conditions)
    - Conduction (neutrals and some electrons)
    - Convection
    - Radiation from neutrals
    - Other processes?
  - The temperature of the gas might not equilibrate with the wall temperature
    - May have implications for target injection
  - Xe at low pressure (~10-50 mTorr) might not be effective in reducing ion energy deposition and flux on chamber wall
- Other scoping calculations
  - Chamber mass transport (presented by P. Sharpe)
  - Chamber wall interaction (presented by A. Hassanein)



## **Effectiveness of Conduction Heat Transfer to Cool Chamber Gas to Preshot Conditions**

- Simple transient conduction equation for a sphere containing gas with an isothermal boundary condition(T<sub>w</sub>)
  - k<sub>xe</sub> is poor (~0.015 W/m-K at 1000K, and ~0.043 W/m-K at 5000 K)
  - At higher temperature electron conductivity of ionized gas in chamber will help

(assumed ~ 0.1 W/m-K for  $n_e = n_o$ and 10, 000 K)

- Argon better conducting gas
- T decreases from 5000K to 2000K in ~2 s for  $k_g = 0.03$  W/m-K
- Even if k<sub>g</sub> is increased to 0.1 W/m-K, it does not help much (~ 0.6 s)

#### Temperature History Based on Conduction from 50 mTorr Gas in a 5 m Chamber to a 1000K Wall





## **Effectiveness of Convection Heat Transfer to Cool Chamber Gas to Preshot Conditions**

- Simple convection estimate based on flow on a flat surface with the fluid at uniform temperature
- Use Xe fluid properties
- Assume sonic velocity
  - c ~ 500 m/s
  - Re ~ 700 for L = 1 m
  - Nu ~ 13
  - $h \sim 0.4 \text{ W/m}^2\text{-}K$
- Lower velocity would result in lower h but local eddies would help
  - Set h between 0.1 and 1 W/m<sup>2</sup>-K representing an example range
- T decreases from 5000K to 2000K, in ~0.1 s for h = 0.4 W/m<sup>2</sup>-K
- Increasing h to 1 W/m<sup>2</sup>-K helps but any reduction in h rapidly worsens the situation (e.g. ~0.4 s for 0.1 W/m<sup>2</sup>-K)

#### Temperature History Based on Convection from 50 mTorr Gas in a 5 m Chamber to a 1000K Wall





### **Effectiveness of Radiation Heat Transfer to Cool Chamber Gas from Mid-level Temperature (~5000K) to Preshot Conditions**

- Xe is monoatomic and has poor radiation properties
  - Complete radiation model quite complex
  - Simple engineering estimate for scoping calculations
  - No emissivity data found for Xe
  - Simple conservative estimate for Xe using CO<sub>2</sub> radiation data
  - T decreases from 5000K to 2000K, in ~1 s (would be worse for actual Xe radiation properties)

$$\mathbf{q_r''} = \boldsymbol{\sigma} \ \boldsymbol{\epsilon}_{\mathrm{w}} \ (\boldsymbol{\epsilon}_{\mathrm{g}} \mathbf{T}_{\mathrm{g}}^{-4} - \boldsymbol{\alpha}_{\mathrm{g}} \mathbf{T}_{\mathrm{w}}^{-4})$$

#### Temperature History Based on Radiation from 50 mTorr Gas in a 5 m Chamber to a 1000K Wall





## **Effectiveness of Heat Transfer Processes to Cool Chamber Gas (Xe) to Preshot Conditions is Poor**

**Conservative estimate of Xe temperature (K) following heat transfer from 5000K** 

Time:	<b>0.1</b> s	<b>0.2</b> s	<b>0.5</b> s	~1 s
Conduction:				
k=0.03 W/m-K	<b>4700</b>	<b>4500</b>	3600	2700
k=0.1 W/m-K	3900	3200	2200	1500
Convection:				
h=0.1 W/m <sup>2</sup> -K	3800	3000	1650	1200
h=0.4 W/m <sup>2</sup> -K	<b>1950</b>	1220	~1000	
h=1 W/m <sup>2</sup> -K	1250			
Xe Radiation:				
(assum. $CO_2 \epsilon$ and $\alpha$ )	3500	2850	2300	2200

- Only possibility is convection with high velocity and small length scales (optimistic requiring enhancement mechanisms) and/or appreciable gas inventory change per shot (by pumping)
- Background plasma in the chamber might help in enhancing heat transfer (e.g. electron heat conduction, recombination)



### Effectiveness of Chamber Gas (Xe) to Attenuate Ions (e.g. D and He from Direct Drive Target Spectra) is Poor at Low Pressure (~10-50 mTorr)

e.g. ~10 mTorr Xe



- Energy attenuation and ion flux decrease marginal
  - Minor effect on wall temperature and erosion
  - Minor effect on reducing energy and number of ions potentially causing damage on long term armor integrity



### **Effectiveness of Chamber Gas (Xe) at Higher Pressure to Attenuate Ions (e.g. D and He from Direct Drive Target Spectra)**

#### e.g. ~100 mTorr Xe



- Effect on energy attenuation and ion flux decrease becomes significant for gas pressures > ~100 mTorr
- Ion attenuation would be markedly enhanced by the presence of ionized gas in the chamber (electron slowing down, collective processes?)

### **Plasma Effect Could Help?**

- Need to include impact of plasma on chamber self consistently
- Increase in heat transfer
  - Recombination processes
  - Enhanced radiation
  - Electron conductivity
- Increase in stopping power (reduce ion flux)
- Zero dimensional plasma scoping model to understand relative importance of these effects (just started)
  - Cannot assume that system in equilibrium





## Why Xe?

- Low pressure Xe gas as a neutral will not be effective
  - Poor heat transfer capability
  - No appreciable reduction in flux and energy of ions
- If a low pressure gas is needed why not consider another gas based on:
  - Minimizing species in chamber
  - Facilitating pumping
  - Minimizing laser breakdown
  - Better heat transfer (more effective chamber gas temperature relaxation)
- Tendency to settle on previous design and material choices
- It is healthy to reconsider reasons behind some of these choices
  - e.g. study starting from fundamental issues to determine which chamber gas to use



## Concluding Remarks on Chamber Physics and Clearing Effort

- Team has been assembled and responsibilities defined
- Major processes, relevant models and key variables have been identified
- Several lessons from initial effort
  - Chamber physics processes very complex
  - Need to understand and characterize them for effective code development
- Scoping calculations have been performed and relative importance of processes and parameters assessed
  - Poor heat transfer performance and minor ion attenuation effect of low-P neutral Xe gas
  - Why Xe?
  - Choice of gas should be made on other considerations, such as:
    - Pumping
    - Minimizing chamber constituents
    - Chamber gas temperature relaxation
    - Laser breakdown
- Plasma effects might help (zero-D model for scoping calculations)
  - Proceeding with Code implementation

